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Ten micron-thick undoped SnO<sub>2</sub> layers grown by spray pyrolysis for

microheater fabrication

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**Abstract** 

Micron-thick layers of tin oxide are advantageous for the fabrication of high power density transparent

microheaters operating at elevated temperatures and harsh environments. Here, we report growing ~10 μm-

thick undoped SnO<sub>2</sub> on alumina substrates and using the produced layers for the fabrication of long life

microheaters operating at temperatures as high as 1000 °C. The spray pyrolysis of tin chloride dissolved in

pure ethanol on hot alumina chips is utilized for layer deposition. The morphology of the grown crystallites is

determined by the substrate temperature while the growth rate is temperature-independent in the 300-500 °C

range. The average grain size in the layers grown at higher substrate temperatures is larger, but the

microstructure is hardly altered by subsequent thermal annealing at 600 °C. The 10 µm-thick layers are

mainly comprised of large (110) facets; this dominance becomes more profound at higher growth

temperatures. The produced layers are utilized for long life high power density microheater fabrication; the

resistance change recorded over six months of continuous operation at 350 °C is less than 5%. These devices

withstand short term operation at temperatures as high as 1000 °C.

**Keywords:** Spray pyrolysis; Tin oxide; Thick films; Deposition; Transparent conductor; Microheater;

Introduction

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1

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